

Application No.: 09/930,847

Docket NO.: JCLA6974-R

REMARKS

Discussion of Office Action Rejections

The Advisory Action indicated that "the conductive layer adjacent to the spacers directly serves as a source/drain region" has raised new issue, and the previous amendments was not entered.

Applicant has submitted the REC, in which the amendments have been made. The typographic error in independent claim 15 is also amended.

As previously discussed, the features of the present invention include the contrast surface formed between the spacer with respect to the gate layer and the polysilicon layer. Due to this contrast layer, the selective conductive layer can be selectively deposited on the gate layer and the polysilicon layer but not on the spacer. As a result, the selective conductive layer on the polysilicon layer adjacent to spacer can directly serve as the source/drain region.

In addition to the reasons given in previous discussions, the prior art at least fails to disclose the contrast surface of the invention, which can be used to form the selective conductive layer and a part of the selective conductive layer can directly serve as the source/drain region.

For at least the foregoing reasons, Applicant respectfully submits that claims 15- 20 patently define over the prior art, and should be allowed.

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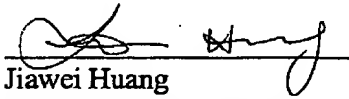
CONCLUSION

For at least the foregoing reasons, it is believed that all pending claims 15-20 are in proper condition for allowance. If the Examiner believes that a telephone conference would expedite the examination of the above-identified patent application, the Examiner is invited to call the undersigned.

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Respectfully submitted,
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